

ATTORNEY DOCKET NO. NIL 2 6 10 TO THE ANSMITTAL FORM 70020.0058US01 U.S. APPLICATION SERIAL NO. CONFIRMATION NO. 1719 10/743,809 sed on all correspondence after initial filing) FILING DATE **December 24, 2003** GROUP ART UNIT EXAMINER 1752 Rosemary E. Ashton Eiji YONEDA et al. TITLE OF APPLICATION ONIUM SALT COMPOUND AND RADIATION-SENSITIVE RESIN COMPOSITION

ADDRESS TO:	ADDRESS TO: Mailstop Amendment Commissioner for Patents P.O. BOX 1450 ALEXANDRIA, VA 22313-1450								
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

REQUEST FOR RECONSIDERATION

ATTORNEY DOCKET NO. 70020.0058US01 U.S. APPLICATION SERIAL NO. CONFIRMATION NO 10/743,809 1719 FILING DATE

December 24, 2003

INVENTOR(S)

Eiji YONEDA et al.

GROUP ART UNIT

Rosemary E. Ashton

1752

TITLE OF APPLICATION

ONIUM SALT COMPOUND AND RADIATION-SENSITIVE RESIN **COMPOSITION**

Mailstop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed April 26, 2006, please consider the following remarks.

Remarks begin on page 2 of this paper.